

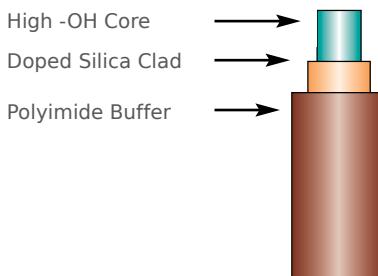
High -OH Deep UV Enhanced

Polymicro SILICA/ SILICA Optical Fiber FDP

For applications in the deep UV region (190nm - 325nm), effects of high levels of UV radiation on the transmission of a silica core optical fiber must be considered. Solarization changes depend on the type of fiber used as well as the intensity and spectral output of the UV source. These changes are wavelength dependent.

CHARACTERISTICS

Step index	Sterilizable and bio-compatible – USP class VI*	Proof tested to 100kpsi
Numerical aperture: 0.22 ± 0.02 full acceptance cone: 25.4 degrees	High laser damage threshold	Operating temperature: -65°C to +300°C
Operating wavelength down to to 190nm	High -OH silica core, doped silica clad	High -OH Core
Ultra high UV transmission	Polyimide buffer standard	Doped Silica Clad
Ultra low UV solarization	Polyimide concentricity < 3µm	Polyimide Buffer
Superior radiation resistance	Custom core sizes, buffers and assemblies available	

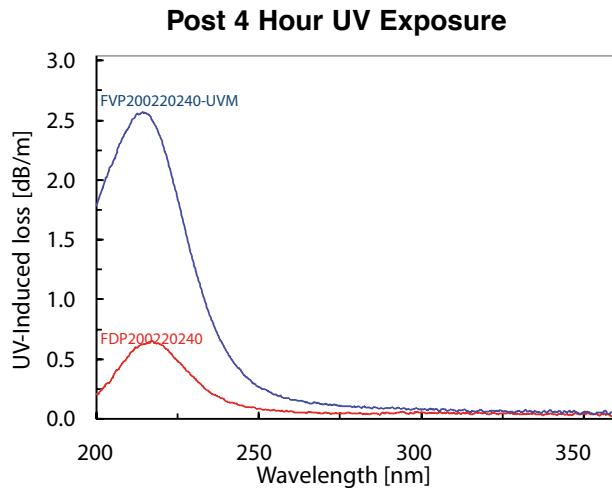
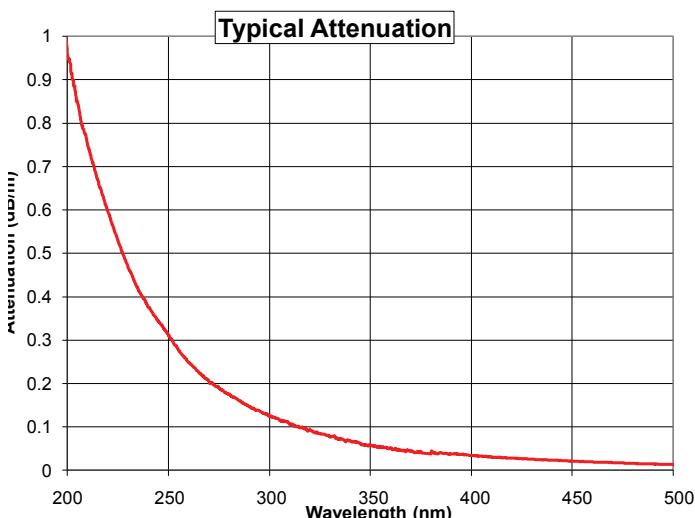


Specifications

Product Descriptor	Core (µm)	Clad (µm)	Buffer (µm)
FDP100110125	100 ± 3	110 ± 3	124 ± 3
FDP200220240	200 ± 4	220 ± 4	240 ± 5
FDP400440480	400 ± 8	440 ± 9	480 ± 7
FDP600660710	600 ± 10	660 ± 10	710 ± 10

Note: The items listed in this table are standard configurations and sizes. Other configurations may be available on request.

* The end manufacturer is responsible for bio-compatibility and sterilization testing and validation studies.



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